

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE AS  
DESIGNATED/ELECTED OFFICE

Applicant: Philippe Cormont, et al. ) Title: Method and Device for Lithography by  
Serial No.: To be assigned ) Extreme Ultraviolet Radiation  
Intl. Appl. No.: PCT/FR2004/002226 ) Group Art Unit: To be assigned  
Intl Filing Date: 01 September 2004 ) Examiner: To be assigned  
 ) Filed: Herewith

PRELIMINARY AMENDMENT ACCOMPANYING FILING OF NATIONAL STAGE  
APPLICATION UNDER 35 U.S.C. 371

*Mail Stop PCT*  
*Commissioner for Patents*  
*P.O. Box 1450*  
*Alexandria, Virginia 22313-1450*

Sir:

Prior to examination, please amend the accompanying application as follows:

**Amendments to the Specification** begin on page 2 of this paper.

**Amendments to the Claims** are reflected in the listing of claims which begins on  
page 3 of this paper.

**Remarks/Arguments** begin on page 11 of this paper.